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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/025,907	12/26/2001	Yun-Ho Jung	8733.565.00	7489
30827	7590 07/29/2004		EXAMINER	
	A LONG & ALDRIDG	PADGETT, MARIANNE L		
1900 K STREET, NW WASHINGTON, DC 20006			ART UNIT	PAPER NUMBER
			1762	
		DATE MAII CD: 07/20/2004		

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(a)	- Ma				
	Application No.	Applicant(s)					
Advisory Action	10/025,907	JUNG, YUN-HO	Т				
	Examiner Marianna I. Badgett	Art Unit					
The MAN INC DATE of this communication appe	Marianne L. Padgett	1762					
The MAILING DATE of this communication appe		·					
THE REPLY FILED 12 July 2004 FAILS TO PLACE TH Therefore, further action by the applicant is required to a final rejection under 37 CFR 1.113 may only be either: ('condition for allowance; (2) a timely filed Notice of Appetexamination (RCE) in compliance with 37 CFR 1.114.	avoid abandonment of this application 1) a timely filed amendment whi	cation. A proper replich places the application	ply to a cation in				
PERIOD FOR REPLY [check either a) or b)]							
a) The period for reply expires <u>3</u> months from the mailing date of the final rejection.							
b) The period for reply expires on: (1) the mailing date of this Advevent, however, will the statutory period for reply expire later th ONLY CHECK THIS BOX WHEN THE FIRST REPLY WAS 706.07(f). Extensions of time may be obtained under 37 CFR 1.136(a). The day	an SIX MONTHS from the mailing date o FILED WITHIN TWO MONTHS OF TH	of the final rejection. IE FINAL REJECTION. S	See MPEP				
Extensions of time may be obtained under 37 CFR 1.136(a). The day the been filed is the date for purposes of determining the period of extensions of the shortened (b) above, if checked. Any reply received by the Office later than three moleanned patent term adjustment. See 37 CFR 1.704(b).	sion and the corresponding amount of the d statutory period for reply originally set in	e fee. The appropriate ext the final Office action; or	tension fee under (2) as set forth in				
1. A Notice of Appeal was filed on Appellant's Brief must be filed within the period set forth in 37 CFR 1.192(a), or any extension thereof (37 CFR 1.191(d)), to avoid dismissal of the appeal.							
2. The proposed amendment(s) will not be entered because:							
(a) ⊠ they raise new issues that would require further consideration and/or search (see NOTE below);							
(b) ☑ they raise the issue of new matter (see Note below);							
(c) they are not deemed to place the application in better form for appeal by materially reducing or simplifying the issues for appeal; and/or							
(d) ☐ they present additional claims without canceling a corresponding number of finally rejected claims.							
NOTE: See Continuation Sheet.							
3. Applicant's reply has overcome the following rejection	ction(s):						
4. Newly proposed or amended claim(s) would canceling the non-allowable claim(s).	be allowable if submitted in a s	separate, timely filed	d amendment				
5.⊠ The a) affidavit, b) exhibit, or c) request fo application in condition for allowance because: See	r reconsideration has been consecutive Continuation Sheet.	sidered but does NO	OT place the				
6. The affidavit or exhibit will NOT be considered becaused by the Examiner in the final rejection.	cause it is not directed SOLELY	' to issues which we	ere newly				
7. For purposes of Appeal, the proposed amendment explanation of how the new or amended claims we	i(s) a) will not be entered or bould be rejected is provided bel	o) will be entered low or appended.	and an				
The status of the claim(s) is (or will be) as follows:							
Claim(s) allowed:							
Claim(s) objected to:							
Claim(s) rejected: 674							
Claim(s) withdrawn from consideration: 1-4.							
8. The drawing correction filed on is a) approved or b) disapproved by the Examiner.							
9. Note the attached Information Disclosure Statement(s)(PTO-1449) Paper No(s)							
10. ☑ Other: See Continuation Sheet							
	MARIANN PRIMARY	NE PADGETT Y EXAMINER					

U.S. Patent and Trademark Office PTOL-303 (Rev. 11-03)

Continuation Sheet (PTOL-303) 10/025,907

Application No.

Continuation of 2. NOTE: All claimed movements being effected by "stepping" is a new issue, since previously all movement was generic (i.e. neither continuous nor discontinuous or stepped), and NO attempt to provide support for these changes was made by applicant, hence they potentially encompass New Matter, but [0036] may provide support for discrete small scale movements of the mask for crystallizing within a "block", however the mask's movement is controlled by a mask stage, NOT by the mask itself as in claim 5.

Continuation of 5. does NOT place the application in condition for allowance because: applicants' citation of the lines in Im et al (6,368,945 B1) that teach movement of the masking system and/or the sample stage (col.4, lines 39-49), then repeating the previously refuted argument that this same teaching does not exist in Im et al is NOT convincing. Applicants' other allegation that appears to be arguing that all movement in Im et al is continuous, not step is also in accurate, since only Im et al's scanning in one direction, exemplified by Y is continuous, while movement in the perpendicular direction, X, is taught to be stepped with examples of 2 cm or 3 micrometer given. See col.7, lines 5-26+and col.9, lines 35-67+, and fig. 1B & 7. Particularly note that while the exemplary discussion all refers to the sample stage being moved, lines 39-44 of col.4 specifically says that the movement illustrated in figure 1B can result from "motion ... of the sample translation stage 180 and/or the movement of the mask system 150". Since those movements include stepping as disclosed, obvious arguments concerning the proposed amendment would be required. Note in figure 1B, since the mask is producing beamlet that follow the path denoted by 25, 30, 35, 45, 50 55,...75+, and ref# 5 & 6 are column equivalent to the claimed blocks, stepping movement to complete crystallization of both individual blocks & of other blocks is taught.

Continuation of 10. Other: It is noted that since applicants ignored the examiner's question concerning the "mask controlling fine movement of the mask" in lines 6-7 of claim 5, they intend for their mask to be self moving (i.e. NOT moved by the mask stage).